

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/594,537  
Applicant : Ho-Seong Nam et al.  
Filed : September 27, 2006  
Title : CHEMICAL MECHANICAL POLISHING SLURRY  
: COMPOSITION FOR SHALLOW TRANCH ISOLATION  
: PROCESS OF SEMICONDUCTOR  
Group Art Unit : 1765 Confirmation No. : 3363  
Examiner : Not Yet Assigned Customer No. : 28289

INFORMATION DISCLOSURE STATEMENT

MAIL STOP AMENDMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

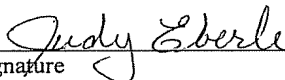
Pursuant to 37 C.F.R. §§1.56, 1.97 and 1.98, Applicants hereby submit this Information Disclosure Statement together with completed Form PTO/SB/08A and a copy of the foreign references identified therein.

The above-identified application is the United States national stage of International Application No. PCT/KR2005/000859, filed 03/24/2005, which was published as International Publication WO 2006/004258 on 01/12/2006. The Notice of Acceptance indicates that a copy of the International Search Report from the PCT application was filed with the U.S. Patent & Trademark Office on 09/27/2006.

I hereby certify that this correspondence is being electronically submitted to the United States Patent and Trademark Office on the date below.

Judy Eberle

(Name of Person Mailing Papers)

  
Signature

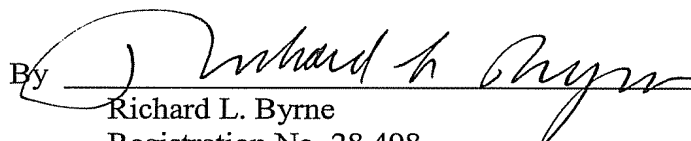
October 26, 2007  
Date

U.S. Patent Nos. 6,117,783, 5,480,476, 6,313,039, and 6,458,291 identified on the Form PTO/SB/08A are cited as relevant prior art by the International Search Authority in the International Search Report. U.S. Patent Nos. 5,738,800, 5,759,917, and Korean Publication No. 20010062282 identified on the Form PTO/SB/08A are identified as background art in the Specification in paragraphs [5], [6], and [7], respectively, and are relevant for the reasons identified therein. An English language Abstract for Korean Publication No. 20010062282 is included herein along with the Korean language reference. U.S. Patent Nos. 6,491,843, 6,544,892, and 6,468,910 identified on the Form PTO/SB/08A are all U.S. Patents related to the above-mentioned Korean publication.

The cited United States patents are not enclosed pursuant to the waiver of the requirement under 37 C.F.R. §1.98(a)(2)(i) for U.S. patent applications filed after June 30, 2003.

Pursuant to 37 C.F.R. §1.97(b)(3), no fee is believed to be due for the submission of this Information Disclosure Statement, as it is being submitted before the mailing date of a first Office Action on the merits. Nevertheless, the Assistant Commissioner for Patents is hereby authorized to charge any fees which may be required to Deposit Account No. 23-0650.

Respectfully submitted,  
THE WEBB LAW FIRM

By   
Richard L. Byrne  
Registration No. 28,498  
Attorney for Applicants  
700 Koppers Building  
436 Seventh Avenue  
Pittsburgh, PA 15219-1845  
Telephone: (412) 471-8815  
Facsimile: (412) 471-4094  
E-mail: [webblaw@webblaw.com](mailto:webblaw@webblaw.com)